

CE13L05P0S4

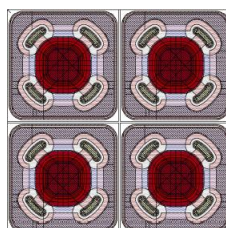
4-Channel Ultra Low Capacitance ESD Diode Array

Wafer Information

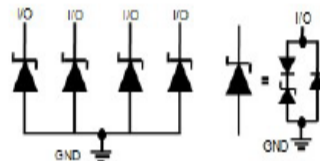
Item	Description
Wafer Size	6 inch (150mm)
Wafer Thickness	150um ± 10um
Die Size (with scribe lane)	334um x 334um
Bond Pad Opening	71um x 71um
Scribe Lane Width	40um
Gross Die Per Wafer	143,000
Top Metal (for wire bond)	4μm AlSiCu
Backside Metal (for die bond)	Sn

- Complies with IEC 61000-4-2 standards:
Contact discharge: ±20kV

Die Appearance



Circuit Diagram



Absolute Maximum Ratings (T_A=25°C unless otherwise specified)

Parameter	Symbol	Value	Unit
Peak Pulse Power (8/20μs)	P _{pk}	56	W
Peak Pulse Current (8/20μs)	I _{PP}	4	A
Operating Temperature Range	T _J	-55 to +125	°C
Storage Temperature Range	T _{stg}	-55 to +150	°C

Electrical Characteristics (T_A=25°C unless otherwise specified)

Parameter	Symbol	Min	Typ	Max	Unit	Test Condition
Reverse Working Voltage	VRWM			5	V	
Breakdown Voltage	VBR	6.0			V	I _T = 1mA
Reverse Leakage Current	IR			100	nA	VRWM = 5V
Forward voltage	VF			1.2	V	I _F =15mA
Clamping Voltage	VC			10	V	I _{PP} = 1A (8 x 20μs pulse)
Clamping Voltage	VC			14	V	I _{PP} = 4A (8 x 20μs pulse)
Junction Capacitance	C _J		0.45	0.60	pF	VR = 0V, f = 1MHz, I/O to GND
Junction Capacitance	C _J		0.22	0.30	pF	VR = 0V, f = 1MHz, IO to IO

Note: Electrical parameters are only for die, performance may alter after assembly.